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Recent advances on thermoelectric materials

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Abstract By converting waste heat into electricity through the thermoelectric power of solids without producing greenhouse gas emissions, thermoelectric generators could be an important part of the solution to today's energy challenge. There has been a resurgence in the search for new materials for advanced thermoelectric energy conversion applications. In this paper, we will review recent efforts on improving thermoelectric efficiency. Particularly, several novel proof-of-principle approaches such as phonon disorder in phonon-glass-electron crystals, low dimensionality in nanostructured materials and charge-spin-orbital degeneracy in strongly correlated systems on thermoelectric performance will be discussed.

Keywords energy materials, thermoelectric, nanostructure, strongly correlated system, phonon-glass-electron crystal, charge-spin-orbital degeneracy

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1 Introduction

Current annual global energy consumption is 4.1×10^{20} J [equivalent to 13 terawatts (TW)]. By the end of the century, the projected population and economic growth will more than triple this global energy consumption rate

[1]. This demand for increasingly large contributions to global primary energy supply and requirements due to the threat of climate change (e.g., clean energy without the emission of additional greenhouse gases) define today's energy challenge: to search for new, clean and renewable prospective energy resources. Solar energy is currently believed to be the most prominent renewable energy source. Compared with other energy resources such as exploitable hydroelectric resources (<0.5 TW), the cumulative energy in all the tides and ocean currents in the world (<2 TW), and globally extractable wind power (2–4 TW), solar energy provides about 120 000 TW striking the Earth, which can be exploited on the needed scale to meet global energy demand [1]. All routes for utilizing solar energy exploit the functional steps of capture, conversion, and storage. The development of high efficiency thermoelectric materials is one of the important research directions for solar power utilization.

The thermoelectric effect refers to the phenomenon of the direct conversion of temperature differences to electric voltage and vice versa. Thermoelectric generators can be used for converting heat generated by many sources, such as solar radiation, automotive exhaust, and industrial processes, to electricity. On the other hand, thermoelectric coolers can be used to make refrigerators and other cooling systems. Considering the extremely high reliability in thermoelectric devices (solid state devices without moving parts), they have wide applications in infrared sensors, computer chips and satellites. The drawback in these thermoelectric devices is their low efficiency, which limits wider applications. If the efficiency can be significantly improved, thermoelectric devices can be an important part of the solution to today's energy challenge. Therefore, how to improve thermoelectric ef-

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efficiency becomes the key issue in this research field.

In this paper, we will review recent efforts on improving thermoelectric efficiency. Different from several existing comprehensive reviews [2–8] on thermoelectric materials, here we will focus on strategies for improving thermoelectric efficiency, namely, the figure of merit for thermoelectric performance. Particularly, several novel proof-of-principle approaches such as phonon disorder in phonon-glass-electron crystals, low dimensionality in nanostructured materials and charge-spin-orbital degeneracy in strongly correlated systems on thermoelectric performance will be discussed.

2 Background and brief history of thermoelectrics

There are three well-known major effects involved in the thermoelectric effect: the Seebeck, Peltier, and Thomson effects. In 1821, Thomas Johann Seebeck discovered that a conductor generates voltage when subjected to a temperature gradient. This phenomenon is called the Seebeck effect and can be expressed as

$$V = \alpha \Delta T \quad (1)$$

where V is thermoelectric voltage, ΔT is temperature gradient, and α is the so-called Seebeck coefficient (shown in Fig. 1) [9]. The Peltier effect is the reverse of the Seebeck effect — it refers to the temperature difference induced by voltage gradient. The Thomson effect relates the reversible thermal gradient and electric field in a homogeneous conductor [10].

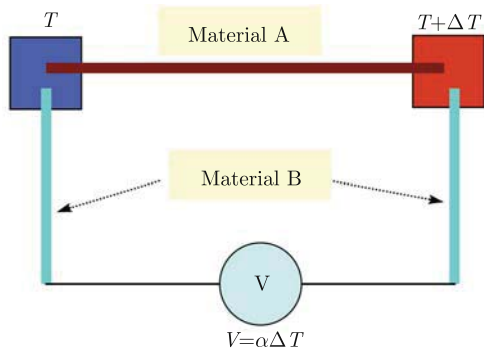


Fig. 1 Simplified diagram of the Seebeck effect. Material A is cooled at one end (in blue color) with low temperature T and heated at the other end (in red color) with high temperature $T + \Delta T$. This results in a voltage difference as a function of temperature difference (ΔT).

Based on the thermoelectric effects described above, one can build a thermoelectric module for power generation [Fig. 2 (a)] or cooling system [Fig. 2(b)]. The efficiency of thermoelectric devices is characterized by the

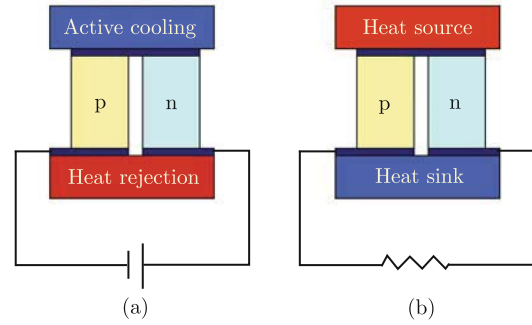


Fig. 2 Illustration of thermoelectric modules. (a) Cooling module. (b) Power generation module.

thermoelectric material's figure of merit [11, 12], which is a function of several transport coefficients:

$$ZT = \frac{\sigma S^2 T}{\kappa_e + \kappa_l} \quad (2)$$

where σ is the electrical conductivity, S is the Seebeck coefficient, T is mean operating temperature and κ is thermal conductivity. The subscripts e and l in κ refer to electronic and lattice contributions, respectively. The larger the figure of merit, the better the efficiency of the thermoelectric cooler or power generator. Therefore, there is significant interest in improving figure of merit in thermoelectric materials for many industrial and energy applications. In fact, the history of thermoelectric materials can be characterized by the progress of increasing ZT , as shown in Fig. 3.

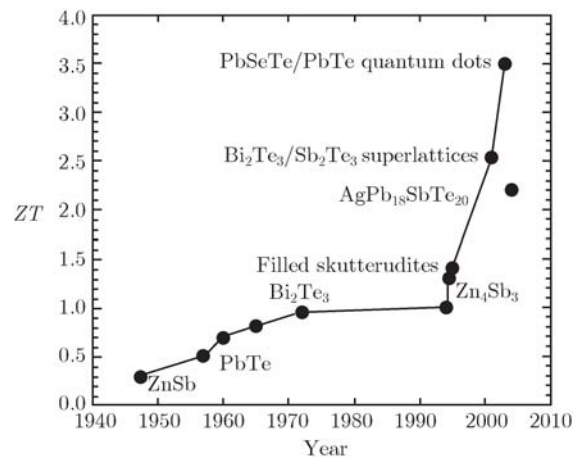


Fig. 3 ZT of many typical thermoelectric materials as a function of year. (after Refs. [13, 14])

The history of applications of thermoelectric materials is strongly associated with their efficiency. The early application of the thermoelectric effect is in metal thermocouples, which have been used to measure temperature and radiant energy for many years [2]. From the

late 1950s, research on semiconducting thermocouples have appeared, and semiconducting thermoelectric devices have been applied in terrestrial cooling and power generation, and later in space power generation, due to their competitive energy conversion compared with other forms of small-scale electric power generators [2]. By the 1990s, many thermoelectric-based refrigerators can be found in the market, and starting around 2000, thermoelectric technology has been used to enhance the functions of automobiles such as thermoelectric cooled and heated seats [14]. However, low efficiency (with $ZT < 1$) of thermoelectric devices has largely limited their application. With the discovery of new materials with increasing ZT (e.g., $ZT > 1$), many new potential applications of thermoelectric technology have opened up. Particularly, its promising application in energy solution has recently attracted much attention [1].

The immense interest in thermoelectric materials can be obviously observed by simply counting the publications on thermoelectric topics (see Fig. 4). While during 1970 – 1990, the number of papers almost remained flat, there are two noticeable periods when publications increased: (i) from 1955 to 1965, the number of papers increased linearly with total publication per year less than 100; (ii) from 1995 to the present, publications on thermoelectrics has grown exponentially. From this figure, it is clearly seen that thermoelectric materials are gaining more interest.

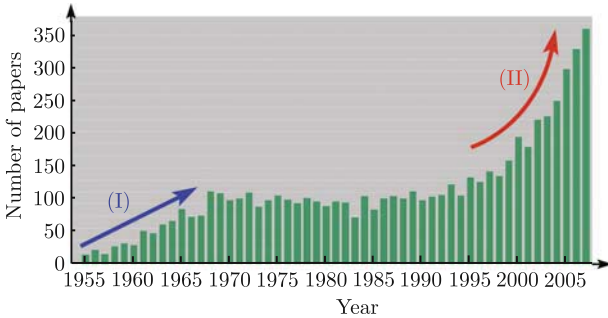


Fig. 4 The number of papers on thermoelectric materials published as a function of year from 1955 to 2007. (after Ref. [15])

3 Strategies for improving figure of merit

In this section, we will review several strategies for improving thermoelectric efficiency, namely, the figure of merit for thermoelectric performance. According to Eq. (2), one can clearly see that, in principle, the direction of increasing the figure of merit (ZT) is to increase electrical conductivity and the Seebeck coefficient and to decrease thermal conductivity. However, in reality, it is not easy

to improve ZT due to the fact that σ , S , κ are all coupled with each other, and all are also strongly dependent on the material's crystal structure, electronic structure and carrier concentration [16]. Moreover, for a good thermoelectric material, not only is a high figure of merit over a wide operating temperature range required, but also sound mechanical, metallurgical and thermal characteristics to be used in practical thermoelectric generators [2].

3.1 What class of materials can be potential thermoelectric materials: metals, semiconductors or insulators?

As we mentioned before, the figure of merit of a material is influenced by its electronic structure. It is well known from an electronic point of view that many materials can be simply classified into metals, semiconductors, and insulators. These three different classes of materials can be characterized by zero, small and large band gaps, respectively, or alternatively, by free-charge-carrier concentration. The first question that arises will be: what class of materials can be potential thermoelectric materials? The comparison of thermoelectric properties of metals, semiconductors and insulators at 300 K is shown in Table 1 and illustrated in Fig. 5. It is clear that metals have very good electrical conductivity ($\sim 10^6 \Omega^{-1} \cdot \text{cm}^{-1}$). However, their very low Seebeck coefficient ($\sim 5 \mu\text{V} \cdot \text{K}^{-1}$) and large thermal conductivity do not make them the most desirable materials for thermoelectric applications [2]. For insulators with large band gaps, although they have large a Seebeck coefficient ($\sim 1000 \mu\text{V} \cdot \text{K}^{-1}$), their extremely low electrical conductivity ($\sim 10^{-12} \Omega^{-1} \cdot \text{cm}^{-1}$) results in a small value of $S^2\sigma$, and thus a small Z ($\sim 5 \times 10^{-17} \text{K}^{-1}$), which is far smaller than that of metal ($\sim 3 \times 10^{-6} \text{K}^{-1}$). The optimal thermoelectric materials with a large value of $S^2\sigma$ is located in the region near the crossover between semiconductor and metal (see Fig. 5), with optimized carrier concentration of about $1 \times 10^{19} \text{cm}^{-3}$.

Table 1 Comparison of thermoelectric properties of metals, semiconductors and insulators at 300 K. (after Ref. [2])

Property	Metals	Semiconductors	Insulators
$S / (\mu\text{V} \cdot \text{K}^{-1})$	~ 5	~ 200	~ 1000
$\sigma / (\Omega^{-1} \cdot \text{cm}^{-1})$	$\sim 10^6$	$\sim 10^3$	$\sim 10^{-12}$
Z / K^{-1}	$\sim 3 \times 10^{-6}$	$\sim 2 \times 10^{-3}$	$\sim 5 \times 10^{-17}$

It should be noted that the discussion presented above is a simplified picture without considering the detailed band structure of materials. Moreover, lattice thermal conductivity is assumed to be similar among these materials. This simplified picture is already quite useful to narrow the region for better thermoelectric materi-

als. Contributions from the lattice and effect of complex band structure will be covered in the following sections. The effects of strong electron correlation will also be discussed.

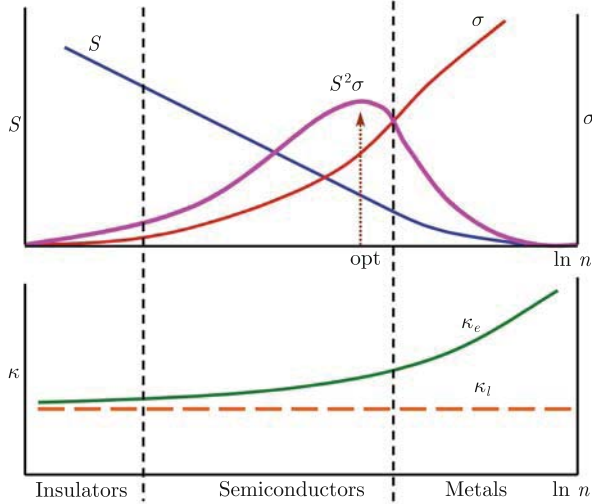


Fig. 5 Seebeck coefficient S , electrical conductivity σ , $S^2\sigma$, and electronic (κ_e) and lattice (κ_l) thermal conductivity as a function of free-charge-carrier concentration n . The optimal carrier concentration is about $1 \times 10^{19} \text{ cm}^{-3}$, which is indicated by an arrow. (after Refs. [2, 17])

3.2 What kind of band structure gives a better figure of merit?

Since σ , S , κ_e are determined by electronic band structure, then a question will be naturally asked: what kind of band structure gives a better figure of merit? This question has been addressed by Mahan and Sofo [12] from a mathematical point of view. Using the transport coefficients obtained by solving the Boltzmann equation, and keeping all properties characterizing the material inside the transport distribution function $\Sigma(x)$, they obtained the expression of figure of merit [12]:

$$ZT = \frac{\xi}{1 - \xi + A} \quad (3)$$

where $\xi = \frac{I_1^2}{I_0 I_2}$, $A = \frac{1}{\alpha I_2}$. The dimensionless integrals I_n are defined as $I_n = \int dx \frac{e^x}{(e^x + 1)^2} s(x) x^n$, and the dimensionless transport distribution function is given by $s(x) = \hbar a_0 \Sigma(\mu + x k_B T)$, which is measured from the chemical potential μ and scaled by the inverse temperature. There are two parameters $\alpha = (k_B/e)^2 T \sigma_0 / \kappa_l$, and $\sigma_0 = e^2 / (\hbar a_0)$ which are determined by physical constants, where k_B is Boltzmann's constant, e is the electronic charge, \hbar is the reduced Plank's constant, and a_0 is the Bohr's radius [12].

By analyzing Eq. (3), it has been found that if the transport distribution takes the Dirac delta function, the figure of merit can be maximized. In other words, if electronic density of state near the chemical potential has a sharp singularity, the figure of merit can be very large. For example, assuming density of states has delta function, $N(\varepsilon) = n_i \delta(\varepsilon - b k_B T)$, with n_i being the concentration of energy levels, then the figure of merit can be expressed as [12]:

$$(ZT)_{\max} = 0.146 \frac{v d n_i k_B}{\kappa_l} \quad (4)$$

where v is the group velocity of the carriers and d is the mean-free path. By choosing some typical parameters for a good thermoelectric material, the authors of Ref. [12] showed that a possible figure of merit as high as $ZT=14$ can be obtained. Such high ZT is proposed to be achievable in rare-earth compounds [12]. However, they also found that with a background added in the density of states, ZT is significantly reduced [12]. Therefore, the results obtained by Mahan and Sofo pointed to some new indications for searching for good thermoelectric materials: (i) a very narrow distribution of energy carriers, (ii) high carrier velocity in the direction of the applied electric field, and (iii) very small percentage ($<1\%$) of background in density of states under a sharp peak.

3.3 First principles calculations of electron transport coefficient

Previous sections narrowed the region to search for good thermoelectric materials, and band structure that will give a better ZT is also described. These are general discussions without complex band structures in real materials. In this section, we will review recent efforts on first principles calculation of electron transport coefficients in real materials.

To make computations of thermoelectric components accessible to first principles calculation, the expression of group velocity \mathbf{v} should be rewritten to include the momentum operator \mathbf{p} [18,19]:

$$\mathbf{v}_k = \frac{1}{\hbar} \frac{\partial \varepsilon_k}{\partial \mathbf{k}} = \frac{1}{m} \langle k | \mathbf{p} | k \rangle \quad (5)$$

where ε_k is the band energy, \mathbf{k} is a wave vector, $|k\rangle$ are the electronic states, and m is the electron mass. The matrix element in Eq. (5) can be computed *ab initio* such as the optical matrix element in an *optic* package of WIEN2k code [20], which is a program based on full potential augmented plane wave (FP-APW) scheme in the density functional theory (DFT) [21, 22] framework. By solving the Boltzmann equation, the transport coefficient

cients related to the electronic part of the thermoelectric effect can be written as [12, 18, 19, 23]:

$$\sigma = e^2 \sum_{\mathbf{k}} \left(-\frac{\partial f_0}{\partial \varepsilon} \right) \mathbf{v}_{\mathbf{k}} \mathbf{v}_{\mathbf{k}} \tau_{\mathbf{k}} \quad (6)$$

$$S = e k_B \sigma^{-1} \sum_{\mathbf{k}} \left(-\frac{\partial f_0}{\partial \varepsilon} \right) \mathbf{v}_{\mathbf{k}} \mathbf{v}_{\mathbf{k}} \tau_{\mathbf{k}} \frac{\varepsilon_{\mathbf{k}} - \mu}{k_B T} \quad (7)$$

$$\kappa_e = k_B^2 T \sum_{\mathbf{k}} \left(-\frac{\partial f_0}{\partial \varepsilon} \right) \mathbf{v}_{\mathbf{k}} \mathbf{v}_{\mathbf{k}} \tau_{\mathbf{k}} \left(\frac{\varepsilon_{\mathbf{k}} - \mu}{k_B T} \right)^2 - T \sigma S \quad (8)$$

where f_0 is the Fermi function, $\tau_{\mathbf{k}}$ is the relaxation time, and μ is the chemical potential. After computing matrix elements in Eq. (5) and assuming constant relaxation time approximation, the transport coefficients in Eqs. (6)–(8) can be directly calculated, and thus the ZT of materials can be obtained accordingly. This method has been used to calculate thermoelectric properties of Bi_2Te_3 [18, 24, 25], Sb_2Te_3 [19], PbTe [26], CoSb_3 [25], and LiZnSb [16]. With advances in the development of first principles methods and powerful modern computers, it is expected that computational efforts will play an increasingly more important role in searching for better thermoelectric materials.

3.4 Effects of strong electron correlation

So far, what we have discussed is mainly related to conventional semiconductors with itinerant motion of charge carriers (broad-band systems). There is another class of materials, for example, transition metal oxides, in which electrons are strongly correlated. These materials are often characterized by a narrow localized band and hopping conduction. For these strongly correlated materials, a different theory from what was presented in the previous section is required to describe their thermoelectric properties, because the treatment of transport properties derived by the Boltzmann equation may be insufficient [27–29], while the Kubo formalism [30] for the transport coefficients of an interacting system should be used.

Effects of strong correlation on thermopower are often discussed based on the Hubbard model [28, 29, 31–34], t - J model [35], or t - V model [36]. We will use a simple Hubbard model to illustrate how strongly correlation affects thermopower.

For a simple Hubbard model, its Hamiltonian can be expressed as

$$H = -t \sum_{i,\sigma} (c_{i,\sigma}^\dagger c_{i+1,\sigma} + c_{i+1,\sigma}^\dagger c_{i,\sigma}) + U \sum_{i,\sigma} n_{i\sigma} n_{i-\sigma} \quad (9)$$

where t is the transfer integral of an electron between neighboring sites, $c_{i\sigma}^\dagger$ and $c_{i\sigma}$ are creation and annihilation operators of electron with spin σ at sites i , $n_{i\sigma}$ is the local charge density, and U is the on-site Coulomb interaction. At a high temperature limit ($t \ll k_B T$), the thermopower is given by [28, 29, 32]

$$S = -\frac{k_B}{e} \frac{\partial \ln g}{\partial N} \quad (10)$$

where g is the degeneracy, which is calculated for a system with N_A sites and N electrons distributed randomly but with certain restrictions [29]. Here, only one-dimension cases will be considered for simplification.

The degeneracy for spinless Fermions can be written as

$$g = \frac{N_A!}{N!(N_A - N)!} \quad (11)$$

and thus the well-known Heikes formula can be obtained using Stirlings approximation and differentiating with respect to N [27–29]:

$$S = -\frac{k_B}{e} \ln[(1 - n)/n] \quad (12)$$

where $n = N/N_A$ is charge density, i.e., the ratio of electrons to sites. It has been pointed out by Chaikin and Beni [29] that Eq. (12) is physically applicable to systems in enormous magnetic fields. Similarly, in the case of fermions with spin (spin-up and spin-down electrons can be distributed randomly among the N_A sites independently, i.e., these electrons have no interaction, $k_B T \gg U$), the degeneracy becomes [29]

$$g = \sum_{N_\uparrow=0}^N \left(\frac{N_A!}{N_\uparrow!(N_A - N_\uparrow)!} \frac{N_A!}{N_\downarrow!(N_A - N_\downarrow)!} \right) \quad (13)$$

here $N_\uparrow + N_\downarrow = N$, and the thermopower can be obtained:

$$S = -\frac{k_B}{e} \ln[(2 - n)/n] \quad (14)$$

Compared with spinless Fermions, this is the generalized Heikes formula for the spin-polarized case. In the case of a strongly correlated system with a large electron-electron on-site repulsion, U , (two electrons with either spin up or down cannot occupy a single site at the same time, $k_B T \ll U$), the total degeneracy is similar to Eq. (11) with spin degree of freedom (2^N) included, and can be written as

$$g = \frac{2^N N_A!}{N!(N_A - N)!} \quad (15)$$

accordingly, the thermopower can be expressed as

$$S = -\frac{k_B}{e} \ln[2(1-n)/n] \quad (16)$$

The effect of strong correlation can be seen from the difference between Eq. (14) and Eq. (16), which is illustrated in Fig. 6.

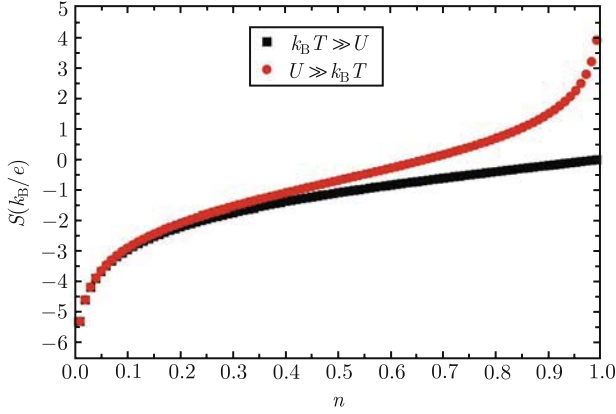


Fig. 6 The comparison of thermopower obtained in two cases: $k_B T \gg U$ and $U \gg k_B T$, namely, Eq. (14) and Eq. (16), respectively.

There has been a recent report [32] on efforts to extend the generalized Heikes formula above in realistic cases such as Na_xCoO_2 and $\text{La}_{1-x}\text{Sr}_x\text{CoO}_3$, which are strongly correlated metal oxides with a high value of measured thermopower. In these cases, both the configurations g_3 (g_4) and sites $N_A - M$ (M) of Co^{3+} (Co^{4+}) ions should be considered; the former can be determined by several factors such as Hund's rule coupling, crystal-field splitting, and temperature. Again, under a high temperature limit, the degeneracy can be expressed as

$$g = g_3^{N_A-M} g_4^M \frac{N_A!}{M!(N_A - M)!} \quad (17)$$

and the thermopower can be obtained by [32]

$$S = -\frac{k_B}{e} \ln \left(\frac{g_3}{g_4} \frac{x}{1-x} \right) \quad (18)$$

It is obvious that the thermopower of cobalt oxides is mainly determined by the configuration ratio (g_3/g_4) and site ratio of $\text{Co}^{3+}/\text{Co}^{4+}$. Based on this theory, the combination of low spin states of both Co^{3+} and Co^{4+} will give the largest thermopower. However, unlike thermopower, the resistivity in transition metal oxides is significantly less affected by spin and orbital degrees of freedom [35]. For the generalized case of searching for better thermoelectric materials in strongly correlated systems, it was suggested that small Metal-Oxygen-Metal bond angle, narrow band, strong correlation of electrons, and frustration are the key ingredients [35].

3.5 Effects of lattice contribution

The above discussions are mainly about electronic contributions in thermoelectric materials. Here we will discuss the effects of lattice contribution on thermoelectric figure of merit. A simple formula of lattice thermal conductivity based on classical kinetic theory of gases for any heat-transporting entity can be given as [2]:

$$\kappa_l = \frac{1}{3} C_V \bar{d} \bar{v} \quad (19)$$

where C_V is the specific heat at constant volume, \bar{d} is the average phonon mean-free path, and \bar{v} is the average phonon velocity. At low temperature, κ_l is mainly determined by specific heat ($C_V \sim T^3$, $\bar{d} \sim \text{constant}$, at low T) and thus it increases with temperature ($\kappa_l \sim T^3$); at high temperature, it is inversely proportional to temperature because it is mainly affected by the phonon mean-free path ($C_V \sim \text{constant}$, $\bar{d} \sim T^{-1}$ at high T). Therefore, for many materials, the lattice thermal conductivity usually has a maximum value at intermediate temperature region. However, since Eq. (19) is based on classical kinetic theory, it should not be expected that it is valid for a wide range of materials. Indeed, for some semiconductors with low thermal conductivity, the phonon mean-free path obtained by Eq. (19) is too small, i.e., only in the order of or less than interatomic spacings. Thus the concept of mean-free path here becomes meaningless. A more accurate theory is required to describe the components of thermal conductivity.

Assuming that phonon scattering processes can be represented by frequency-dependent relaxation times, a phenomenological model has been developed by Callaway [37, 38] to calculate the lattice thermal conductivity. The combined relaxation time τ_C is given by [37]

$$\tau_C^{-1} = \tau_P^{-1} + \tau_D^{-1} + \tau_B^{-1} \quad (20)$$

where τ_P is the relaxation time depending on phonon-phonon scattering (e.g., 3-phonon process), including normal and umklapp processes ($\tau_P^{-1} = C_P \omega^2$), $\tau_D^{-1} = C_D \omega^4$ is for point-defect scattering and $\tau_B^{-1} = v_s/L$ is for boundary scattering. Here C_P and C_D are coefficients, v_s is the velocity of sound and L is a characteristic length. Then the lattice thermal conductivity can be calculated by using the formalism of Callaway [37, 38]:

$$\kappa = \frac{k_B}{2\pi^2 v_s} \left(\frac{k_B T}{\hbar} \right)^3 \int_0^{\theta_D/T} \tau_C(x) \frac{x^4 e^x}{(e^x - 1)^2} dx \quad (21)$$

where θ_D is the Debye temperature and $x = \frac{\hbar \omega}{k_B T}$ is the dimensionless variable. From the expression of τ_P^{-1} and τ_D^{-1} , one can see that the relaxation time is strongly

inverse dependent of phonon frequency; this indicates the principal importance of relatively long-wavelength phonons in determining the lattice thermal conductivity [38].

Besides the above phonon scattering processes, Ziman [39, 40] developed a theory of phonon scattering by electrons at low temperatures, and later Steigmeier and Abeles extended the theory to high temperatures [41]. For completeness, we briefly introduce the theory of phonon-electron scattering here. The phonon relaxation time τ_{EP} due to phonon-electron scattering is given for a parabolic electron band by [39, 40]

$$\tau_{EP}^{-1} = \frac{D^2 m^{*3} v}{4\pi \hbar^4 \rho} \left(\frac{k_B T}{\frac{1}{2} m^* v^2} \right) \left[\frac{\hbar \omega}{k_B T} - \ln \frac{1 + \exp(A_2)}{1 + \exp(A_1)} \right] \quad (22)$$

where

$$A_2 = \frac{\frac{1}{2} m^* v^2 - E_F}{k_B T} + \frac{\hbar^2 \omega^2}{8 m^* v^2 k_B T} + \frac{\hbar \omega}{2 k_B T} \quad (23)$$

$$A_1 = \frac{\frac{1}{2} m^* v^2 - E_F}{k_B T} + \frac{\hbar^2 \omega^2}{8 m^* v^2 k_B T} - \frac{\hbar \omega}{k_B T} \quad (24)$$

here D is the deformation potential (or electron-phonon interaction constant), m^* is the density-of-states effective mass, ρ is the density, and E_F is the Fermi energy. This formula describes the intra-valley scattering, which is dominant, as observed in experiments [42]. Adding τ_{EP}^{-1} into the combined relaxation time τ_C [Eq. (20)], one can calculate lattice thermal conductivity by using Eq. (21) with phonon-electron scattering effects.

Now we can justify the effects of several competing factors as described above on lattice thermal conductivity. Figure 7 plots $\tau_C(\omega/\omega_D)^2$ with different combined scattering processes as a function of reduced phonon frequencies (ω/ω_D , here ω_D is the Debye frequency). It is clear that the high-frequency phonons are significantly cut out by point-defect scattering, while the mean-free path of low-frequency phonons are reduced by phonon-electron scattering. The most efficient frequency for carrying heat is located at $\omega \sim 0.15\omega_D$ [41], which means that the heat is mainly carried by the long-wavelength phonons. Therefore, if one can design a special structure to scatter more long-wavelength phonons, lattice thermal conductivity can be significantly reduced, and thus thermoelectric properties can be improved.

Another important issue is the temperature dependence of phonon scattering processes. At very low temperatures, phonon-phonon scattering becomes very weak, while the boundary scattering and phonon-

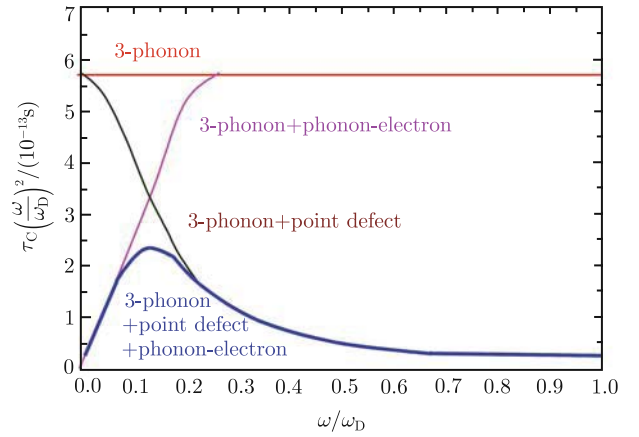


Fig. 7 Comparison of different combined scattering processes in $\tau_C(\omega/\omega_D)^2$ as a function of the reduced phonon frequency. The thermal conductivities are proportional to the areas under the curves. (after Ref. [41])

electron scattering are important. On the other hand, at high temperatures, phonon-phonon scattering is the main process for reducing the mean-free path of phonons. The point-defect scattering can be an important source of scattering at both low and high temperature. By introducing imperfections such as impurities, isotopes, solid solutions, alloys, lattice vacancies, dislocations, lattice disorder and crystal grain boundaries, the thermal conductivity can be significantly reduced and in turn, the thermoelectric properties can be improved.

One of the recent novel approaches to search for good thermoelectric materials is to find or design a new kind of material — the so-called “phonon glass electron crystal” (PGEC) — such as skutterudites [4] or complex layered-structure cobaltites [43–45]. The basic idea is to significantly reduce phonon scattering (similar with glass) but at the same time keep good electric conductivity (electron crystal) by introducing impurities into interstitial voids or cages of skutterudites or by forming distorted rock-salt layers between framework of CoO_2 triangle lattices of cobaltites. This is essentially to enhance the point-defect scattering or boundary scattering and thus reduce thermal conductivity, as described above.

3.6 Effects of dimensionality: nano route to enhance thermoelectric properties

In previous sections, mainly bulk systems have been discussed. In this section, we will review a new approach, i.e., the nano route to enhance thermoelectric properties, by considering the effects of dimensionality.

In 1993, Hicks and Dresselhaus examined the effects of quantum-well [46] and one-dimensional [47] structures on the thermoelectric figure of merit, with the assumption

of parabolic bands and constant relaxation time in a one-band material. Here, by defining a dimensional factor N , ($N=1, 2$, and 3 are for 1-D, 2-D, and 3-D, respectively), and for the case of conduction along the x direction, the dimensionality-dependent thermoelectric figure of merit [46, 47] can be rewritten as

$$Z_N T = \frac{\frac{N}{2} \left(\alpha_N \frac{F_{N/2}}{F_{N/2-1}} - \eta \right)^2 F_{N/2-1}}{\frac{1}{B_N} + \frac{N+4}{2} \cdot F_{N/2+1} - \beta_N \frac{F_{N/2}^2}{F_{N/2-1}}} \quad (25)$$

where $\alpha_N = \frac{14-6N+N^2}{3}$, $\beta_N = \frac{34-9N+2N^2}{6}$, η is the reduced chemical potential, the Fermi-Dirac function F_i is given by, $F_i(\eta) = \int_0^\infty \frac{x^i dx}{\exp(x-\eta)+1}$. The material property dependent parameter B_N is expressed as,

$$B_N = \gamma_N \left(\frac{2k_B T}{\hbar^2} \right)^{N/2} \frac{k_B^2 T \mu_x}{e \kappa_l} \quad (26)$$

where $\gamma_1 = \frac{2}{\pi a^2} (m_x)^{1/2}$ for 1-D, $\gamma_2 = \frac{1}{2\pi a} (m_x m_y)^{1/2}$ for 2-D, and $\gamma_3 = \frac{1}{3\pi^2} (m_x m_y m_z)^{1/2}$ for 3-D cases, respectively. Here, m_x, m_y, m_z are the effective-mass components, μ_x is mobility in the x direction, a is the width of 2-D quantum well or 1-D nanowire, and κ_l is the lattice thermal conductivity, as defined in previous sections.

From Eqs. (25) and (26), one can see that the value of ZT is dependent on η and B_N . For 3-D bulk materials, one can optimize η by optimal doping and B_N by reducing lattice thermal conductivity and/or increasing electron mobility (μ_x). For a 2-D quantum well, with one more degree of freedom, the width of quantum well a can be adjusted to enhance ZT . Obviously, by reducing a , one can increase γ_2 , and thus B_N , then ZT can be largely increased. For 1-D nanowire, the effects of dimensionality are even more significant, i.e., $\gamma_1 \propto \frac{1}{a^2}$. Therefore, ZT can be enhanced by reducing the width (or thickness) of nanowire, as can be clearly seen in Fig. 8. Moreover, in low dimensional cases, with decreasing width of quantum well or nanowire, the boundary scattering (as mentioned in Section 3.5) increases. Lattice thermal conductivity thus decreases and then further enhances B_N and the figure of merit. The lattice thermal conductivity in low dimensional cases due to the phonon confinements has been intensively discussed [48–57].

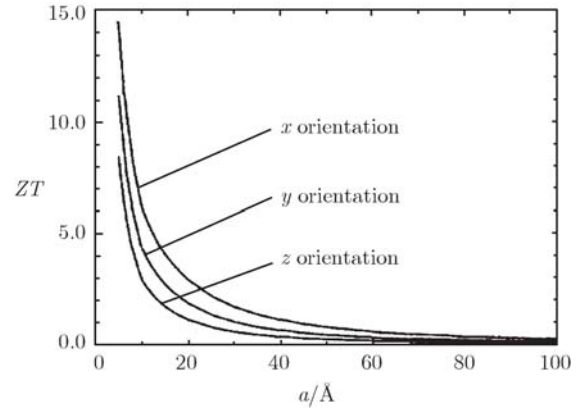


Fig. 8 Optimized ZT as a function of wire width for 1-D wires fabricated along the x, y , and z directions. (after Ref. [47])

4 Survey of new thermoelectric materials

From a historic point of view, the discovery (or development) of thermoelectric materials started from simple metals; conventional semiconductors such as group III-V (e.g., InSb), IV-IV (e.g., SiGe), group IV chalcogenides (e.g., PbTe) [2]; group V chalcogenides (Bi_2Te_3 , Sb_2Te_3) [2, 58, 59] to recent complex materials (e.g., skutterudites [4, 60, 61], Clathrates [62–65], half-Heusler alloys [66], complex chalcogenides [67–69], cobaltites [43–45, 70], and so on), and low-dimensional thermoelectrics (quantum well [71], quantum dot [72], nanowires [73, 74], molecular junctions [75], *et al.*). The trend of finding new thermoelectrics from complex materials or nanostructured materials seems more clear. Here, a brief survey of these typical thermoelectric materials will be given.

Bi_2Te_3 , a typical member of group V chalcogenides, is a well-known good thermoelectric material with $ZT \sim 1$. It is a narrow-gap semiconductor having a rhombohedral crystal structure (as shown in Fig. 9) with the gap of ~ 160 meV. It has been used for refrigeration since the early 1950s [58]. It is the basic constituent of currently the best thermoelectric materials. It was found in middle 1950s that the thermoelectric properties can be improved by making a solid solution of Bi_2Te_3 and isomorphous compounds such as Sb_2Te_3 or PbTe or GeTe and related heavy-metal-based materials [2, 58]. Recent noticeable achievements are: (i) Venkatasubramanian *et al.* reported that p-type $\text{Bi}_2\text{Te}_3/\text{Sb}_2\text{Te}_3$ superlattices may have the highest ZT of about 2.4 at 300 K [59]; (ii) Hsu *et al.* [67] showed that the material system $\text{AgPb}_m\text{SbTe}_{2+m}$ (LAST- m) with $m = 10$ and 18 and doped appropriately may exhibit a high ZT_{max} of 2.2 at 800 K. The achievements of high ZT in these complex or nanostructured chalcogenides largely benefited from a significant reduction of thermal conductivity.

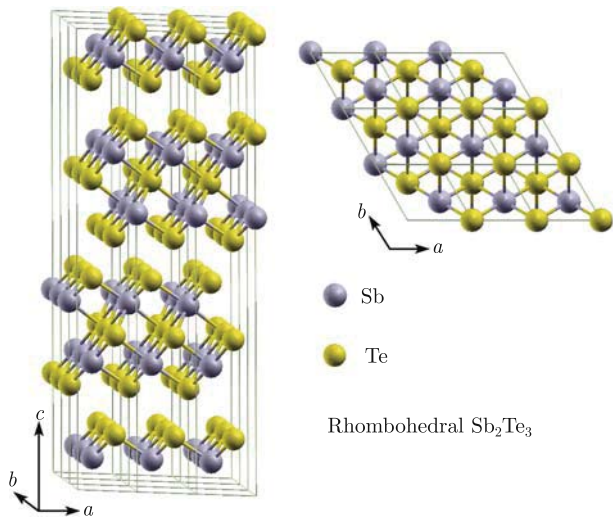


Fig. 9 Crystal structure of Sb_2Te_3 . The Te-Sb-Te-Sb-Te repeating stacking unit can be clearly seen. Left-hand side is perspective view and right-hand side is top view. Bi_2Te_3 has the same crystal structure as that of Sb_2Te_3 .

Another class of materials is PGEC materials, with the concept suggested by Slack [76]. The typical PGEC materials are skutterudites [60, 61], and clathrates [62–65]. Skutterudites such as CoSb_3 or clathrates such as $\text{Sr}_8\text{Ga}_{16}\text{Ge}_{30}$ or $\text{Sr}_4\text{Eu}_4\text{Ga}_{16}\text{Ge}_{30}$ have an open structure (e.g., cage-like structure). When atoms are placed into the interstitial voids or cages of these materials, the lattice thermal conductivity can be substantially reduced compared with that of unfilled skutterudites [4]; at the same time, the materials still have good electrical properties, thus the thermoelectric properties can be enhanced significantly. The typical crystal structure of skutterudite is shown in Fig. 10. The reported ZT value for many typical thermoelectric materials as a function of temperature [8] is illustrated in Fig. 11, so that good thermoelectrics for application at different temperature can be easily compared.

As mentioned in Section 3.4, a new kind of strongly correlated materials, i.e., cobaltites [43–45, 70], are gaining increasing research interest for their thermoelectric properties. Typical examples of cobaltites are shown in Fig. 12. The common features in these materials are that they have (i) large thermoelectric power (Seebeck coefficient) due to the spin and orbital degeneracy of their strongly correlated electron bands, (ii) low thermal conductivity due to their layered structure consisting of triangle-lattice CoO_2 layers or CoO_3 octahedral and diffused atomic layers (or heavy atom chains) or distorted rock-salt blocks.

More recently, silicon nanowires [73, 74] have attracted much attention due to their low thermal conductivity. There is also a recent report on thermoelectricity in

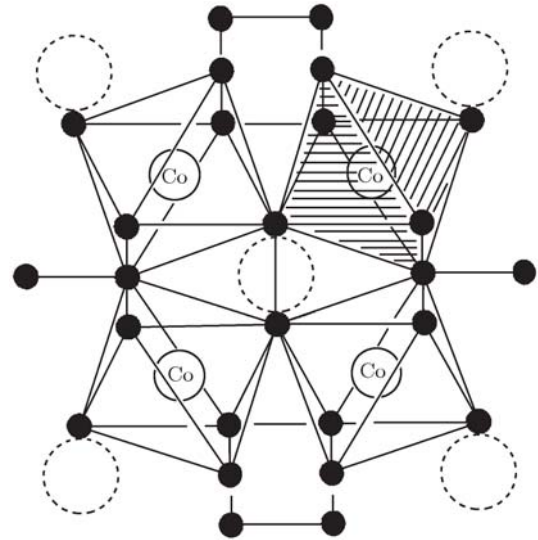


Fig. 10 Atomic structure of the skutterudite unit cell. The lanthanide atoms are located at the cage center (open dot circles), open solid circles are Co atoms, and filled circles are X atoms (X is anion such as Sb for CoSb_3). (after Ref. [4])

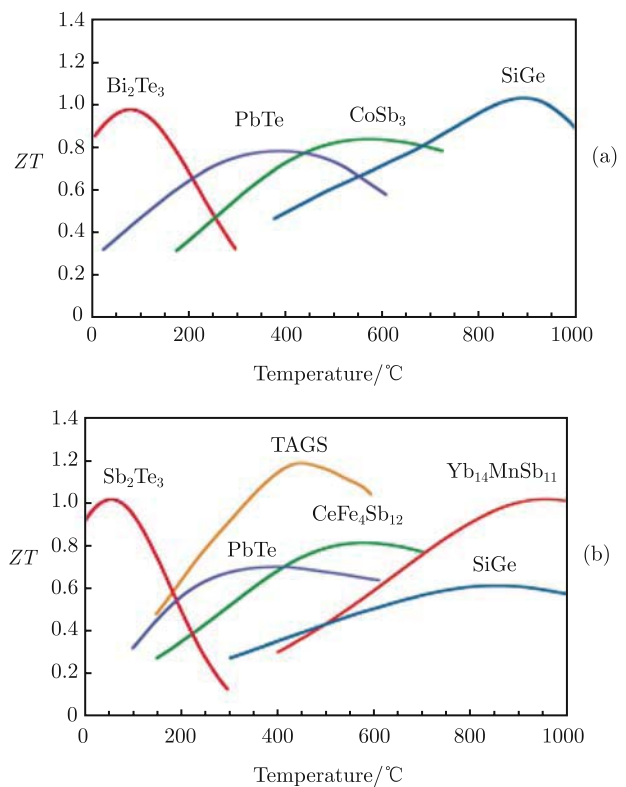


Fig. 11 ZT of some typical thermoelectric materials. (a) n-type and (b) p-type thermoelectrics. TAGS is referred to Te-Ag-Ge-Sb alloy. (after Ref. [8])

molecular junctions [75], which may provide new opportunity to study fundamental thermoelectric problems associated with nano devices.

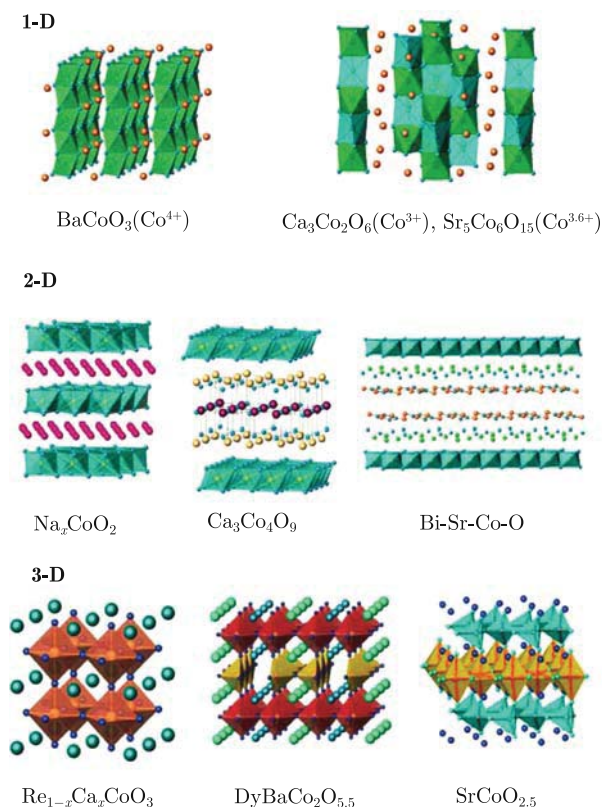


Fig. 12 Typical examples of 1-D, 2-D, and 3-D cobaltites. (after Ref. [43])

5 Summary and outlook

In conclusion, the theories of thermoelectrics and strategies for improving figure of merit in thermoelectric materials have been reviewed. Although there are many advances in both theory and experiments to search for better thermoelectric materials, several issues and challenges still exist. For example, bulk materials with $ZT > 4$ is yet to be achieved. The progress on nano thermoelectrics may provide a new route for better thermoelectric materials, although many questions still need to be addressed. Obviously, the study on thermoelectrics is becoming more important for solving today's energy challenges. Collaboration from scientists among different areas will have clear advantages in this global competition due to the interdisciplinary nature of thermoelectric research.

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